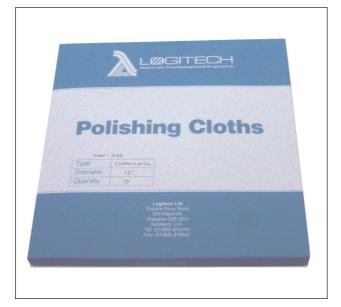
Chemcloth Polishing Cloth



Product Data

8" / 200mm:	0CON-350
10" / 250mm:	0CON-351
12" / 300mm:	0CON-352
14" / 350mm:	0CON-353
18" / 450mm:	0CON-354
22" / 560mm:	0CON-355

Introduction:

Chemcloth Polishing Cloth is designed to satisfy the exacting requirements of chemo-mechanical polishing. The black napped urethane surface layer is intrinsic to the substrate giving superior nap strength and longer pad life.

Chemcloth Polishing Cloths are supplied with a protected selfadhesive backing and each cloth is hermetically sealed in a polythene sachet. Chemcloth is ideally suited to a variety of polishing processes including:

- Production polishing because of the cloth's superior wear resistance and subsequent long life.
- Finishing under corrosive acid and alkaline conditions because of their ability to produce perfect polishes in less time.
- High speed polishing operations because of their superior nap strength.

Ordering Data:

Code	Diameter	Pack size	Comments
0CON-350	8" / 200mm	10	Suitable for final polishing of delicate semiconductor materials, such as Gallium Arsenide, with Chemlox Polishing Fluid. A poromeric pad with vertically orientated pore structure, chemcloth is designed for instantaneous recovery of the pad from polishing pressure, thereby producing the optimum surface finish quality. All Logitech polishing cloths are supplied in self adhesive backed form.
0CON-351	10" / 250mm	10	
0CON-352	12" / 300mm	10	
0CON-353	14" / 350mm	10	
0CON-354	18" / 450mm	10	
0CON-355	22" / 560mm	10	

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